



PATENT
YOR920040022 IBM-272

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

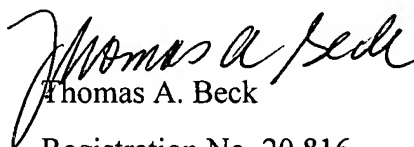
In re Application of : Matthew Colburn, et al.
Serial Number : 10/799,282
Filing Date : March 13, 2004
Examiner : John A. McPherson
Group Art Unit : 1756
For : Method for Fabricating Dual Damascene Structures
Using Photo-Imprint Lithography, Methods for
Fabricating Imprint Lithography Molds for Dual
Damascene Structures, Materials for Imprintable
Dielectrics and Equipment for Photo-Imprint
Lithography Used in Dual Damascene Patterning.

TO: The Honorable Commissioner of Patents
and Trademarks
Post Office Box 1450
Alexandria, VA 22313-1450

CHANGE OF ADDRESS

Please address all future correspondence in this matter to the undersigned at 6136 West
Kimberly Way, Glendale, AZ 85308.

Respectfully Submitted,


Thomas A. Beck

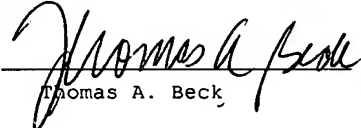
Registration No. 20,816

6136 West Kimberly Way

Glendale, AZ 85308

Telephone (623) 466-0080

I hereby certify that this paper is being transmitted by First Class mail addressed to
Commissioner of Patents & Trademarks, Post Office Box 1450, Alexandria, VA 22313-1450.

Signature: 

Name:

Thomas A. Beck

Date: June 30, 2007